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# Significant improvement in TiO<sub>2</sub> photocatalytic activity through controllable ZrO<sub>2</sub> deposition†

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ZrO<sub>2</sub> was deposited on anatase TiO<sub>2</sub> nanoparticles using 5–80 cycles of atomic layer deposition (ALD). The photocatalytic activity of all samples was evaluated based on the degradation of methylene blue (MB) solution under UV light. The TiO<sub>2</sub> sample with 45 cycles of ZrO<sub>2</sub> deposition (45c-Zr/TiO<sub>2</sub>, 1.1 wt% ZrO<sub>2</sub>) was proved to be the most efficient catalyst with a degradation kinetic constant 10 times larger than that of the pure TiO<sub>2</sub> sample. All samples were characterized using inductively coupled plasma atomic emission spectroscopy (ICP-AES), nitrogen adsorption–desorption, X-ray diffraction (XRD), transmission electron microscopy (TEM), UV-vis diffuse reflectance spectra analysis (UV-DRS), Raman and photoluminescence (PL) techniques. The high photocatalytic activity of 45c-Zr/TiO<sub>2</sub> can be attributed to stronger adsorption in the ultraviolet region and a reduction in the recombination rate of electron/hole pairs.

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## 1. Introduction

Nowadays, TiO<sub>2</sub> has been widely studied as an effective photocatalyst for the degradation of organic pollutants due to its relatively high activity, chemical stability, nontoxicity and low cost.<sup>1</sup> However, the high recombination rate of photo-generated electrons (e<sup>-</sup>) and holes (h<sup>+</sup>) and slow reaction rate of pure TiO<sub>2</sub> have hindered its further application. Thus, the photocatalytic efficiency of TiO<sub>2</sub> needs to be further improved for practical and commercial use.<sup>2</sup>

It is well known that ZrO<sub>2</sub> is an n-type semiconductor with similar physico-chemical properties to those of TiO<sub>2</sub>,<sup>3</sup> and therefore it has been used to prepare ZrO<sub>2</sub> doped TiO<sub>2</sub> photocatalysts because of these similar properties in order to improve the photocatalytic activity of TiO<sub>2</sub>.<sup>3,4</sup> Through ZrO<sub>2</sub> doping, the band gap of the photocatalyst increases and the recombination rate subsequently decreases, which leads to an improvement of the photocatalytic activity. However, almost all previous studies adopted sol–gel and other similar methods to prepare ZrO<sub>2</sub>/TiO<sub>2</sub>, as shown in Table S1,† and thereby the crystal structure and phase composition of the samples were changed due to the mixture of Zr and Ti precursors. High ZrO<sub>2</sub> content would lead to poor anatase crystallinity of TiO<sub>2</sub> and decrease the photocatalytic efficiency; in contrast, ZrO<sub>2</sub> loading that is too low does not ensure an obvious increase in the band gap, and thereby the

e<sup>-</sup>/h<sup>+</sup> recombination rate cannot be reduced effectively. Thus, the enhancement of TiO<sub>2</sub> photocatalytic performance by ZrO<sub>2</sub> doping is restricted, and solving this dilemma is the key to further improving the activity of ZrO<sub>2</sub>/TiO<sub>2</sub>.

In this work, we deposited ZrO<sub>2</sub> on anatase TiO<sub>2</sub> nanoparticles (NPs) *via* different numbers of cycles (5–80) of atomic layer deposition (ALD) to investigate the effect of ZrO<sub>2</sub> in the photocatalytic degradation of methylene blue (MB). The samples were labeled *x*c-Zr/TiO<sub>2</sub>, where *x* refers to the number of cycles of ZrO<sub>2</sub>. ALD is a surface controlled layer-by-layer coating process based on self-limiting surface reactions, and it has been utilized to deposit uniform metal oxide films with sub-nanometer control of film thickness and well controlled film compositions.<sup>5</sup> Through making full use of the advantages of ALD, the ZrO<sub>2</sub> content was controlled at a low level to retain the anatase crystallinity of TiO<sub>2</sub> and the e<sup>-</sup>/h<sup>+</sup> recombination rate decreased due to the high dispersion of ZrO<sub>2</sub> on the surface of TiO<sub>2</sub>.

## 2. Experimental section

### 2.1. Preparation of ZrO<sub>2</sub>/TiO<sub>2</sub> nanoparticles

ZrO<sub>2</sub> was deposited on TiO<sub>2</sub> NPs *via* ALD using tetrakis(dimethylamido)zirconium(IV) (TDMAZ) (electronic grade, ≥99.99%, Sigma-Aldrich) and deionized water as precursors in a fluidized bed reactor, as described in detail elsewhere.<sup>6</sup> Anatase TiO<sub>2</sub> NPs with an average particle size of 20 nm were purchased from US Research Nanomaterials Inc. For a typical run, 5 g of TiO<sub>2</sub> NPs was loaded into the reactor. The reaction temperature was 250 °C. Before the reaction, the particles were first degassed at 250 °C for 3 hours. The particle substrates were fully fluidized with a gas flow rate controlled with mass flow controllers. N<sub>2</sub>

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was used as a flush gas to remove unreacted precursors and any byproducts during the reaction. A typical half deposition cycle used the following sequence: precursor dose, N<sub>2</sub> purge and evacuation. This sequence was repeated alternately for both precursors. 5 (5c-Zr/TiO<sub>2</sub>), 25 (25c-Zr/TiO<sub>2</sub>), 45 (45c-Zr/TiO<sub>2</sub>), 60 (60c-Zr/TiO<sub>2</sub>), and 80 (80c-Zr/TiO<sub>2</sub>) cycles of ZrO<sub>2</sub> ALD were applied on anatase TiO<sub>2</sub> NPs.

## 2.2. Characterization

Inductively coupled plasma-atomic emission spectroscopy (ICP-AES) was used to measure the Zr mass fraction in the ZrO<sub>2</sub>/TiO<sub>2</sub> samples. The surface area of the pure TiO<sub>2</sub> and ZrO<sub>2</sub>-deposited TiO<sub>2</sub> NPs was calculated using the Brunauer–Emmett–Teller (BET) method in a relative pressure range (0.05–0.25) of nitrogen adsorption and desorption isotherms obtained using a Quantachrome Autosorb-1. The photoluminescence (PL) spectra were recorded with a HORIBA FL3-22 spectrometer (HORIBA, Edison, NJ) to evaluate the recombination rate of e<sup>-</sup>/h<sup>+</sup> pairs in the samples. The morphology of ZrO<sub>2</sub> deposited on TiO<sub>2</sub> was directly observed using FEI Tecnai F20 transmission electron microscopy/energy-dispersive X-ray spectroscopy (TEM/EDS). The crystal structure of the TiO<sub>2</sub> and ZrO<sub>2</sub>/TiO<sub>2</sub> samples was analyzed with X-ray diffraction (XRD), and the Raman spectra of the samples were recorded using a Horiba-Jobin Yvon LabRam spectrometer. UV-visible absorbance and diffuse reflectance spectra (DRS) of TiO<sub>2</sub> and ZrO<sub>2</sub>/TiO<sub>2</sub> samples were obtained with a UV-visible spectrophotometer (Varian Cary 5). BaSO<sub>4</sub> was used as an absorbance standard. Details of the characterization are described in the ESI.†

## 2.3. Photocatalytic activity measurement

Degradation of MB was used to evaluate the photocatalytic performance of the TiO<sub>2</sub> and ZrO<sub>2</sub>/TiO<sub>2</sub> samples, as described in detail previously.<sup>7</sup> Briefly, 0.1 g of sample was added to a 100 ml, 10 ppm MB solution. First, the solution was stirred in the dark for 60 min to ensure adsorption/desorption equilibrium. Then, the solution was irradiated using a UV lamp (360 nm UV light) and about 1 ml test sample was collected from the main solution at certain time intervals and filtered through a Millipore filter to make it particle-free for analysis using a UV-vis spectrometer (Varian Cary 50-Bio) at a 664 nm wavelength.<sup>8</sup> The change in concentration of MB in the main solution was recorded over a period of irradiation time.

## 3. Results and discussion

As shown in Fig. 1, the photodegradation efficiency of all ZrO<sub>2</sub>/TiO<sub>2</sub> samples was higher than that of the pure TiO<sub>2</sub>, and with an increasing number of ALD cycles, the photoactivity of the samples kept increasing below 45 ALD cycles of ZrO<sub>2</sub>, then it decreased slightly with further increases in the number of ALD cycles. According to the Langmuir–Hinshelwood kinetic equation (pseudo-first-order reaction),<sup>9</sup> the apparent kinetic constant ( $k_{app}$ ) of the 45c-Zr/TiO<sub>2</sub> sample reached a maximum value (0.127 min<sup>-1</sup>), and its activity exceeded that of pure TiO<sub>2</sub> (0.012 min<sup>-1</sup>) by a factor of more than ten. As shown in Table

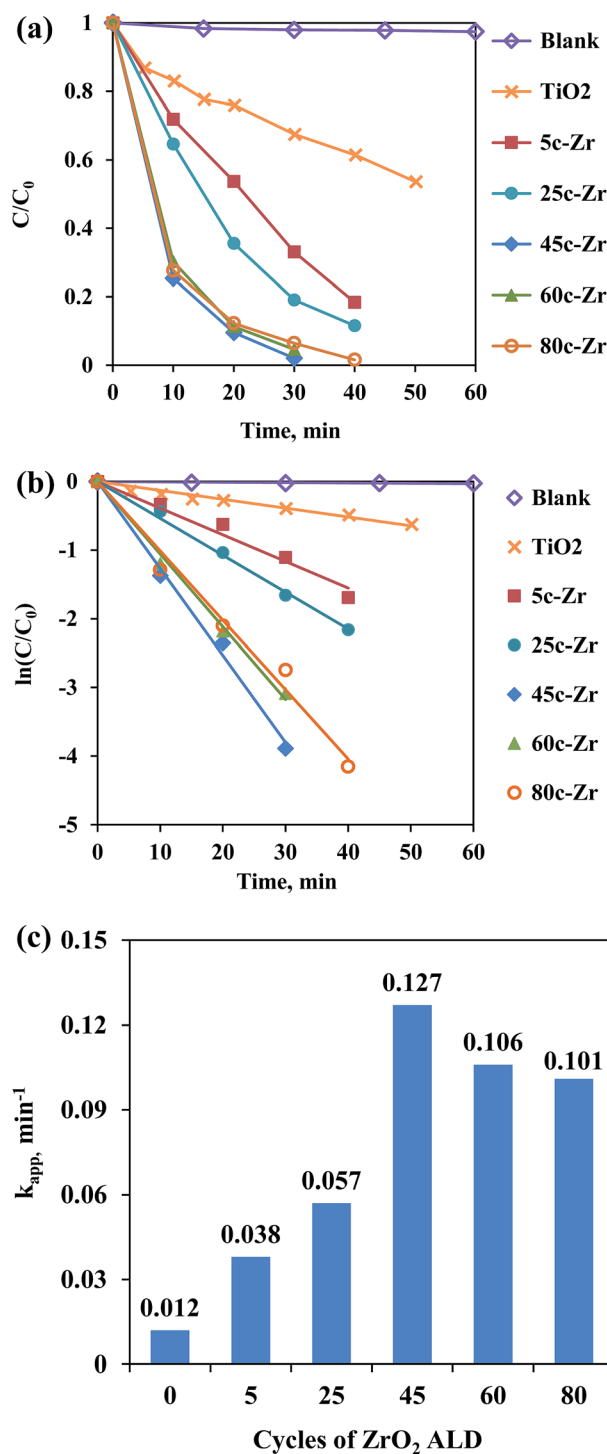


Fig. 1 (a) MB concentration and (b) relative concentration of MB as a function of UV irradiation time over different catalysts, and (c) apparent kinetic constant ( $k_{app}$ , min<sup>-1</sup>) of ZrO<sub>2</sub>/TiO<sub>2</sub> catalysts with different numbers of ZrO<sub>2</sub> ALD cycles.

S1,† Pt ALD and CeO<sub>2</sub> ALD have been applied to the improvement of TiO<sub>2</sub> photoactivity, and they showed, at most, only a 3.0 and 3.3 times increase in photocatalytic activity compared to that of pure TiO<sub>2</sub>, respectively.<sup>7,10</sup> More importantly, ZrO<sub>2</sub> is much cheaper and more economical for large-scale production



compared to Pt. Compared to previously reported  $\text{ZrO}_2/\text{TiO}_2$  photocatalysts,<sup>4</sup> the ALD prepared 45c-Zr/ $\text{TiO}_2$  sample improved the photocatalytic activity of pure  $\text{TiO}_2$  significantly, which proved that  $\text{ZrO}_2$  ALD was one promising strategy to enhance  $\text{ZrO}_2/\text{TiO}_2$  photocatalytic performance (Table S1†). The reasons for the much higher photoactivity of 45c-Zr/ $\text{TiO}_2$  than that of  $\text{TiO}_2$  in this work were investigated.

Firstly, the  $\text{ZrO}_2$  ALD process did not affect the bulk properties of the  $\text{TiO}_2$  NPs (e.g., crystal structure and surface area). As shown in Fig. 2, the  $\text{ZrO}_2$  content of the samples increased steadily (from 0 to 1.5 wt%) with an increasing number of ALD cycles. This is one characteristic of the ALD process. This indicates a constant growth rate of  $\text{ZrO}_2$ . The  $\text{ZrO}_2$  loading was 0.1, 0.5, 1.1, 1.2 and 1.5 wt% in 5c-Zr/ $\text{TiO}_2$ , 25c-Zr/ $\text{TiO}_2$ , 45c-Zr/ $\text{TiO}_2$ , 60c-Zr/ $\text{TiO}_2$ , and 80c-Zr/ $\text{TiO}_2$  samples, respectively. Since the loading of  $\text{ZrO}_2$  deposited on the  $\text{TiO}_2$  NPs was very low, it did not lead to an increase in particle size (decrease of surface area) or poor anatase crystallinity, which would affect the photocatalytic efficiency of the samples. In order to verify this hypothesis, the BET surface area and crystal structure of all samples were analyzed. The BET surface area remained almost constant ( $\sim 70 \text{ m}^2 \text{ g}^{-1}$ ) even after 80 cycles of  $\text{ZrO}_2$  ALD (Fig. 2). The large surface area can provide a lot of surface sites for the adsorption of reactant molecules.

Moreover, based on calculation, 1 g of 80c-Zr/ $\text{TiO}_2$  contained 0.015 g  $\text{ZrO}_2$  ( $5.68 \text{ g cm}^{-3}$ ) and the thickness of  $\text{ZrO}_2$  should be around 0.038 nm ( $0.015/5.68/70 \times 1000 \text{ nm}$ ) if  $\text{ZrO}_2$  formed as a film on the  $\text{TiO}_2$  NPs.<sup>11</sup> The thickness is much thinner than that of a real layer of  $\text{ZrO}_2$  ( $>0.1 \text{ nm}$ ). Thus,  $\text{ZrO}_2$  was highly dispersed on  $\text{TiO}_2$  without forming a film. As shown in Fig. 3, the TEM images of 45c-Zr/ $\text{TiO}_2$  and 80c-Zr/ $\text{TiO}_2$  are similar to that of pure anatase  $\text{TiO}_2$  NPs, and the lattice fringes of 0.35 nm, 0.24 nm, and 0.19 nm correspond to the (101), (004), and (200) planes of anatase, respectively.<sup>12</sup> No  $\text{ZrO}_2$  film was observed, but the ICP-AES (Fig. 2) and EDS (Fig. S1†) verified the existence of Zr on the  $\text{TiO}_2$ . It seems that  $\text{ZrO}_2$  ALD follows an island growth mechanism (Volmer-Weber mechanism) during the initial stages of the ALD process, which could be similar to that of some metal ALD processes.<sup>13</sup>

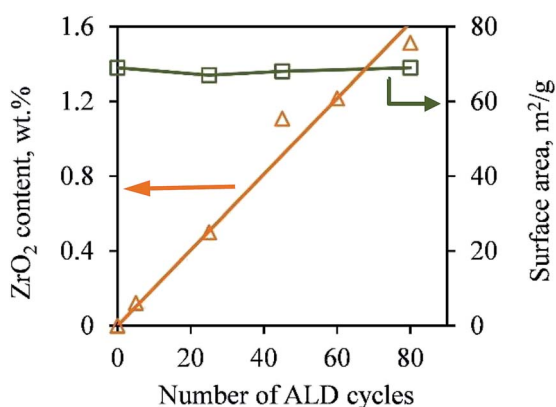


Fig. 2  $\text{ZrO}_2$  content and BET surface area of pure  $\text{TiO}_2$  nanoparticles and  $\text{TiO}_2$  nanoparticles deposited with  $\text{ZrO}_2$  over different numbers of cycles of ALD.

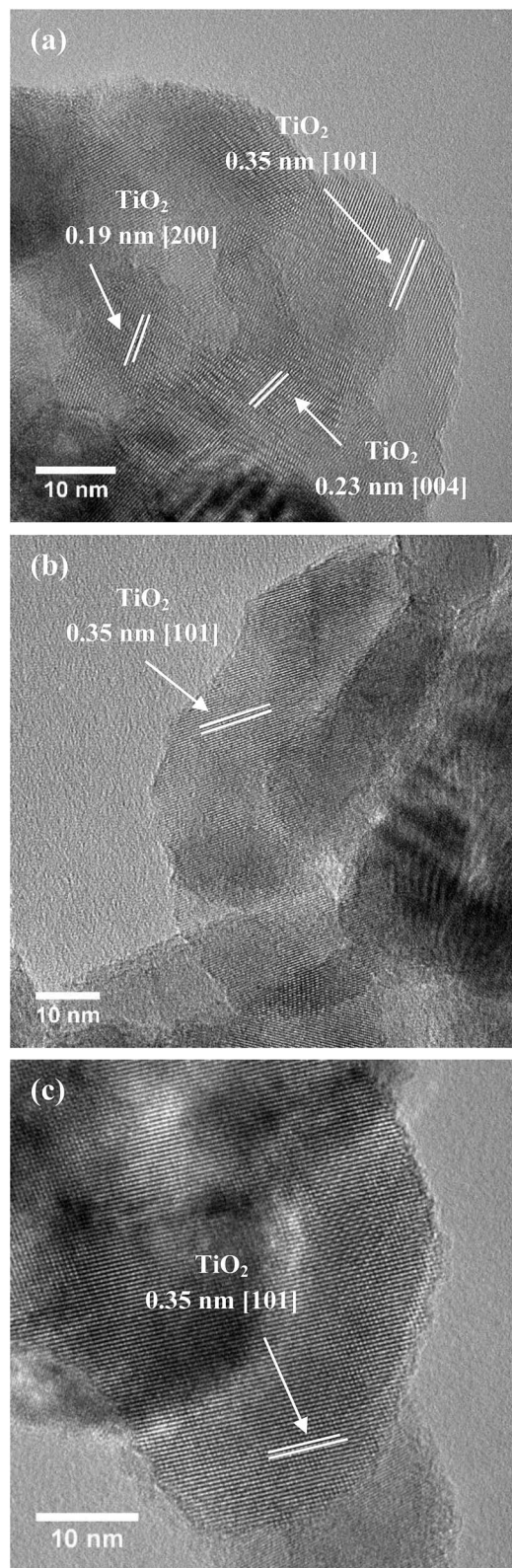


Fig. 3 TEM images of (a)  $\text{TiO}_2$ , (b) 45c-Zr/ $\text{TiO}_2$ , and (c) 80c-Zr/ $\text{TiO}_2$  nanoparticles.

As presented in Fig. 4, the XRD patterns of all samples show peaks appearing at  $2\theta = 25.3^\circ, 37.8^\circ, 48.1^\circ, 53.9^\circ, 55.2^\circ, 62.8^\circ$  and  $75.2^\circ$ , corresponding to the diffraction patterns of (101),



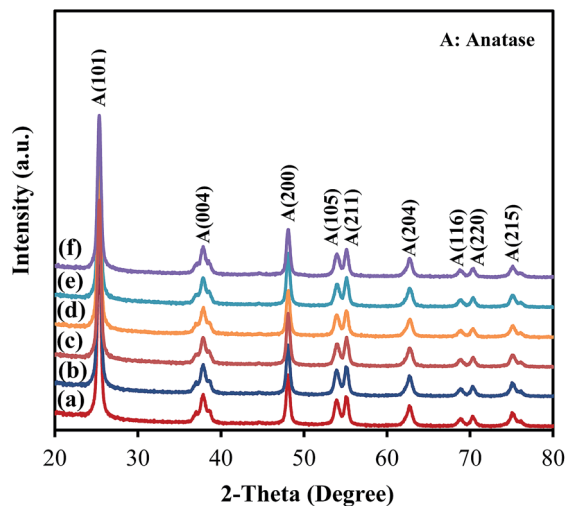


Fig. 4 XRD patterns of (a) TiO<sub>2</sub>, (b) 5c-Zr/TiO<sub>2</sub>, (c) 25c-Zr/TiO<sub>2</sub>, (d) 45c-Zr/TiO<sub>2</sub>, (e) 60c-Zr/TiO<sub>2</sub> and (f) 80c-Zr/TiO<sub>2</sub>.

(004), (200), (105), (211), (204) and (215), respectively, of the pure tetragonal phase of anatase TiO<sub>2</sub>.<sup>14</sup> There was no significant difference in any sample. The TiO<sub>2</sub> in all samples retained the anatase structure after ZrO<sub>2</sub> ALD and no peak corresponded to reflections from ZrO<sub>2</sub>, which could be due to the low loading and amorphous structure of ZrO<sub>2</sub> on TiO<sub>2</sub>. According to the XRD analysis, the TiO<sub>2</sub> crystal size was around 19 nm for all samples, which is close to the actual particle size of TiO<sub>2</sub> (~20 nm). Raman analysis was also performed, and all samples showed three major Raman bands at 397, 517, and 640 cm<sup>-1</sup> (Fig. 5), which are attributed to the Raman-active modes of the TiO<sub>2</sub> anatase phase with symmetries of B<sub>1g</sub>, A<sub>1g</sub>, and E<sub>g</sub>, respectively.<sup>15</sup> Thus, our hypothesis that the surface area and anatase crystallinity of TiO<sub>2</sub> did not change after the ALD process was proved.

Secondly, a larger band gap corresponds to stronger redox ability, which leads to a reduction in the e<sup>-</sup>/h<sup>+</sup> recombination rate and an improvement in photocatalytic activity. Since the

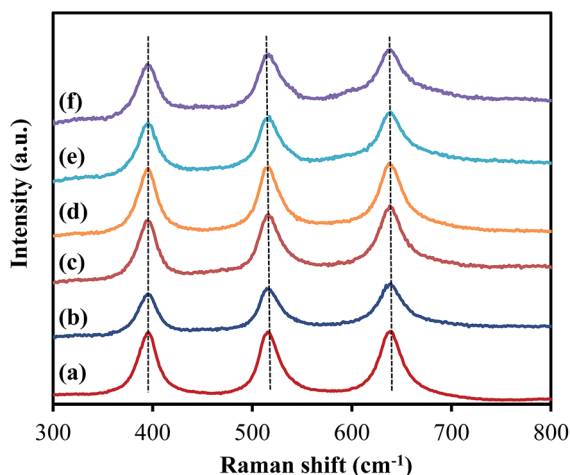


Fig. 5 Raman spectra of (a) TiO<sub>2</sub>, (b) 5c-Zr/TiO<sub>2</sub>, (c) 25c-Zr/TiO<sub>2</sub>, (d) 45c-Zr/TiO<sub>2</sub>, (e) 60c-Zr/TiO<sub>2</sub> and (f) 80c-Zr/TiO<sub>2</sub>.

band gap of ZrO<sub>2</sub> is around 4.6 eV and is larger than that of anatase TiO<sub>2</sub> (3.2 eV),<sup>16</sup> the band gap of ZrO<sub>2</sub>/TiO<sub>2</sub> samples was enlarged after ZrO<sub>2</sub> ALD.<sup>17</sup> As shown in Fig. 6, S2 and S3,† the band gap of the samples kept increasing along with increasing numbers of ALD cycles, which is consistent with previous reports.<sup>4d,18</sup> Because the photocatalytic degradation process can

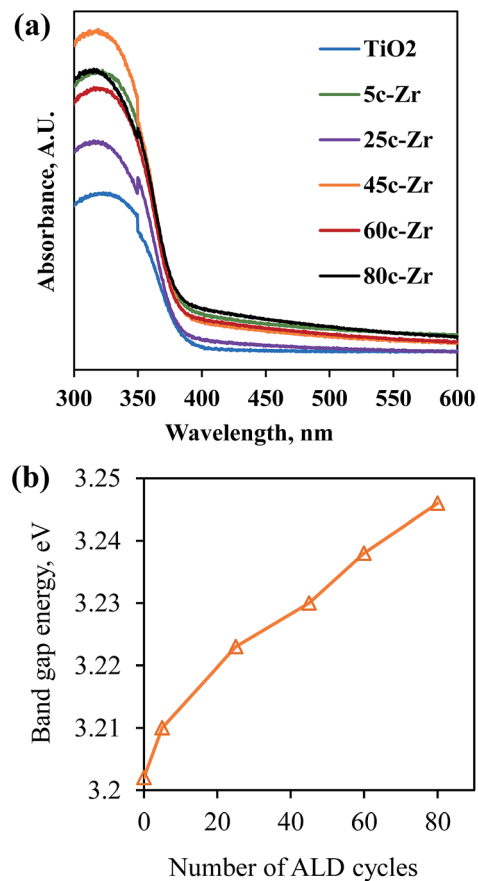


Fig. 6 (a) UV-visible absorption spectra, and (b) the band gap energy of the TiO<sub>2</sub> and ZrO<sub>2</sub>/TiO<sub>2</sub> samples.

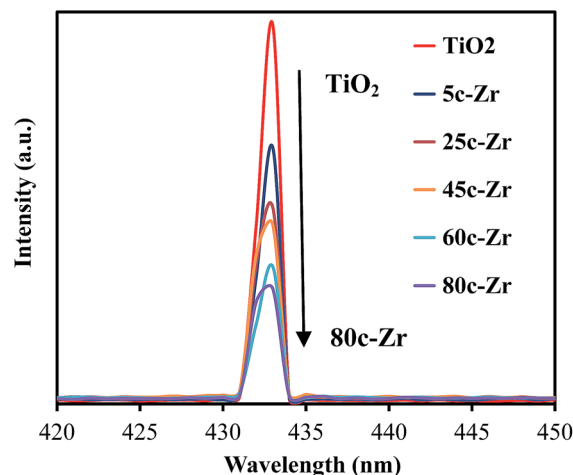


Fig. 7 Photoluminescence spectra of TiO<sub>2</sub> and ZrO<sub>2</sub>/TiO<sub>2</sub> samples excited at 280 nm.



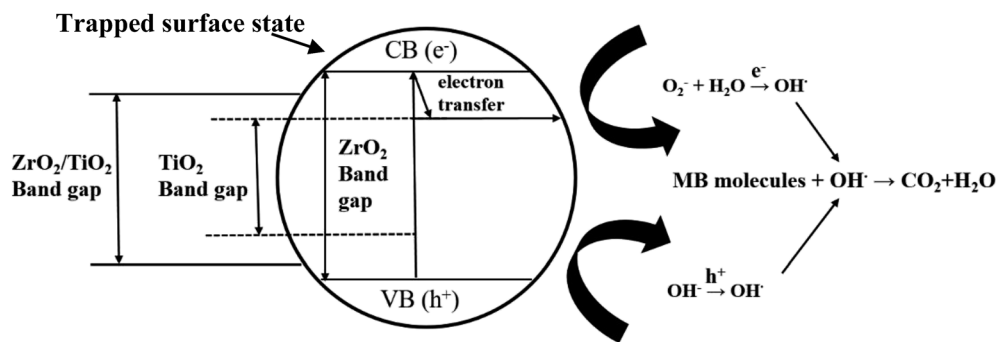


Fig. 8 Proposed mechanism for the photoexcited electron–hole separation and transport processes at the ZrO<sub>2</sub>/TiO<sub>2</sub> interface under UV irradiation.

be considered an electrochemical cell, the increase in band gap results in an enhanced oxidation–reduction potential.<sup>19</sup> However, the photocatalytic activity of 60c-Zr/TiO<sub>2</sub> and 80c-Zr/TiO<sub>2</sub> was lower than that of 45c-Zr/TiO<sub>2</sub>, despite the band gaps of 60c-Zr/TiO<sub>2</sub> and 80c-Zr/TiO<sub>2</sub> being larger than that of the 45c-Zr/TiO<sub>2</sub> sample. This can be explained by samples with too large a band gap being unable to take full advantage of UV light and therefore being unable to generate enough e<sup>-</sup> and h<sup>+</sup> pairs for MB degradation.

Thirdly, there is a fast transfer of the photo-formed electrons from the conduction band (CB) of ZrO<sub>2</sub> to that of TiO<sub>2</sub>, when ZrO<sub>2</sub> was deposited on TiO<sub>2</sub> under UV irradiation, since the bottom of the CB edge of ZrO<sub>2</sub> is about 1.3 eV, which is higher than that of TiO<sub>2</sub>.<sup>4d,16</sup> This electron transfer prevented radiative electron/hole recombination and thereby improved the photocatalytic activity of the 45c-Zr/TiO<sub>2</sub> sample. In order to evaluate the separation rate of the e<sup>-</sup>/h<sup>+</sup> pairs, photoluminescence (PL) analysis was carried out. As shown in Fig. 7, there is only one peak at 433 nm, corresponding to the reflection from the anatase phase of TiO<sub>2</sub>. No other peak was observed in the wavelength range of 300–600 nm. With an increase in the number of ZrO<sub>2</sub> ALD cycles, the PL intensity decreased greatly, which indicated that the separation efficiency of the e<sup>-</sup>/h<sup>+</sup> pairs was enhanced for the ZrO<sub>2</sub>/TiO<sub>2</sub> samples. In other words, the existence of ZrO<sub>2</sub> helped trap the photo-generated charge carriers and inhibited the recombination of the e<sup>-</sup>/h<sup>+</sup> pairs. As shown in Fig. 8, e<sup>-</sup> and h<sup>+</sup> separation may occur between TiO<sub>2</sub> and ZrO<sub>2</sub> in ZrO<sub>2</sub>/TiO<sub>2</sub> since the energy level of TiO<sub>2</sub>, for both the valence band (VB) and CB, falls within the band gap of ZrO<sub>2</sub>. When the electrons were generated from TiO<sub>2</sub> and ZrO<sub>2</sub>, most of the electrons from the CB of ZrO<sub>2</sub> automatically drifted to the CB of TiO<sub>2</sub>. Therefore, the e<sup>-</sup>/h<sup>+</sup> pair recombination could be inhibited and the photocatalytic activity improved. All factors mentioned above worked collectively and resulted in improved photocatalytic activity of 45c-Zr/TiO<sub>2</sub>.

It was also noted that the TiO<sub>2</sub> catalyst containing 1.1 wt% ZrO<sub>2</sub> (45c-Zr/TiO<sub>2</sub>) enhanced the photocatalytic activity the most and it was the optimal amount of deposition for the degradation of MB in this study. However, the optimal ZrO<sub>2</sub> amount is not consistent with that reported in the literature, which reported that the optimal ZrO<sub>2</sub> loading was more than 5%. This could be due to the different preparation methods for the ZrO<sub>2</sub>/

TiO<sub>2</sub> samples.<sup>4a-c</sup> Higher optimal ZrO<sub>2</sub> loading was needed *via* traditional ZrO<sub>2</sub> doping methods because some ZrO<sub>2</sub> was inserted into the interior matrix of the TiO<sub>2</sub> particles and could not work with TiO<sub>2</sub> synergistically. In contrast, in this study, ZrO<sub>2</sub> was highly dispersed on the surface of TiO<sub>2</sub> NPs *via* ALD and thereby the optimal ZrO<sub>2</sub> content was significantly lower. On the other hand, the enlarged band gap of the ZrO<sub>2</sub>/TiO<sub>2</sub> samples in this work becomes a limitation and hinders their practical applications under visible light, although ZrO<sub>2</sub> deposition improved the photocatalytic performance of anatase TiO<sub>2</sub> under UV light. N,<sup>20</sup> S,<sup>21</sup> CeO<sub>2</sub>,<sup>22</sup> and Au/Pd<sup>23</sup> doped TiO<sub>2</sub> catalysts have been reported, and they could decompose organic pollutants under visible light. It is vital and valuable to expand the practical use of TiO<sub>2</sub>-based photocatalysts. The optimization and enhancement of ZrO<sub>2</sub>/TiO<sub>2</sub> photoactivity under visible light are being pursued by this group.

## 4. Conclusions

In summary, different numbers of cycles of ALD were used to deposit ZrO<sub>2</sub> on TiO<sub>2</sub> powders. The 45c-Zr/TiO<sub>2</sub> catalyst showed the highest photocatalytic activity and had a more than ten-fold photocatalytic activity enhancement over pure TiO<sub>2</sub> for the degradation of MB under UV light due to the fact that the fast electron transfer from the CB of ZrO<sub>2</sub> to that of TiO<sub>2</sub> prevented radiative electron/hole recombination. This factor worked collectively with another two factors, the maintained high surface area and the larger band gap of ZrO<sub>2</sub>/TiO<sub>2</sub>, and thus resulted in the significantly improved photocatalytic activity of the samples under UV light. ZrO<sub>2</sub> ALD is a novel and effective strategy to significantly improve the photocatalytic activity of TiO<sub>2</sub>, and it is a potentially promising way to enhance the activity of other photocatalysts.

## Conflicts of interest

The authors declare no competing financial interest.

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